Surface Structures of SrTiO<sub>3</sub>(001) and Ni/SrTiO<sub>3</sub>(001) Studied by Medium Energy Ion Scattering and SR-photoelectron Spectroscopy

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## Abstract

The surface structures of SrTiO<sub>3</sub>(001) and Ni(1-ML)/SrTiO<sub>3</sub>(001) were studied by high-resolution medium energy ion scattering (MEIS) coupled with ultraviolet photo- electron spectroscopy (UPS) using synchrotron radiation. The present MEIS analysis showed that the fraction of TiO<sub>2</sub> face was about 90 % for the SrTiO<sub>3</sub>(001) surface etched in an NH<sub>4</sub>F-HF buffer solution (pH: 3.5 - 3.8) followed by annealing in O<sub>2</sub>-atmosphere. Annealing in ultrahigh vacuum (UHV) at temperatures higher than 650°C generated O-vacancies in the top TiO<sub>2</sub> plane, which was confirmed directly by UPS. Our MEIS analysis also revealed the fact that the fraction of TiO<sub>2</sub> face was decreased by 5-6 % and the ratio of 14 % of the O site in the top TiO<sub>2</sub> plane became vacant by annealing in UHV at 650°C for 1 h. Deposition of one monolayer (ML) Ni onto the clean 1×1 SrTiO<sub>3</sub>(001) surface led to a metallic nature, which was observed by UPS. Reflective high energy electron diffraction analysis showed that the deposited Ni atoms took random sites and subsequent annealing at 400°C in UHV led to formation of single crystal clusters on the surface.